



MASENO UNIVERSITY
UNIVERSITY EXAMINATIONS 2015/2016

**FIRST YEAR FIRST SEMESTER EXAMINATIONS FOR
THE DEGREE OF MASTER OF SCIENCE IN PHYSICS**

MAIN CAMPUS

SPH 823: THIN FILM TECHNOLOGY

Date: 9th May, 2016

Time: 2.00 - 5.00 pm

INSTRUCTIONS:

- Answer ANY THREE questions.



SPH823: THIN FILM TECHNOLOGY

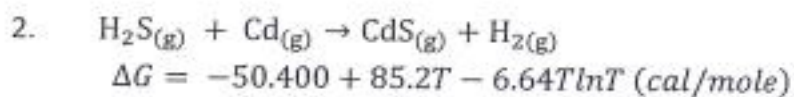
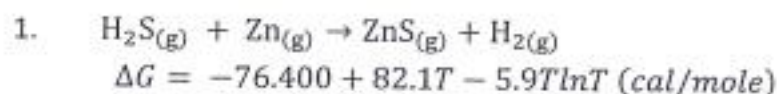
Answer any **three**

- Q1. a) In metallic alloy such as Al-Cu estimate the approximate melt composition required to evaporate films containing 4 wt % copper from a single crucible heated to 1350 K. (8Mks)
- b) Discuss potential reaction types in thermal evaporation of inorganic compounds, giving examples. (6Mks)
- c) Select the appropriate film deposition process (evaporation, sputtering, etc., sources and targets) with reasons, for the deposition of TiO_2 - SiO_2 multilayers on artificial on artificial gems to enhance colour and reflectivity. (6Mks)
[Note: Molecular weight of copper and Aluminum are 63.7 and 27 respectively]
- Q2. a) Give reasons why multilayer optical filters have advantage over other types of filters. (5Mks)
- b) Discuss the deposition processes and their effect on the refractive index n and the extinction coefficient k (5Mks)
- c) After monitoring the thickness of a deposited Au film with a 6.0 (10Mks)

MHz quartz (AT cut) crystal monitor, a researcher decides to confirm his result employing interferometry. A frequency shift of 1022 Hz was recorded for the film measuring 1.00 cm^2 in the area. Interferometry with the Hg green line revealed a displacement of 1.75 fringes across the film step. Are these measurements consistent? If not, suggest plausible reasons why not?

Q3. a) Write a balanced chemical equation for the CVD reaction that produce Al_2O_3 films from the gas mixture consisting of $\text{AlCl}_3 + \text{CO}_2 + \text{H}_2$ (6Mks)

b) Assume you are involved in a project to deposit ZnS and CdS films for infrared optical coatings. Thermodynamic data reveal limiting potential (8Mks)



i) are these reaction endothermic or exothermic?

ii) In practice reactions 1 and 2 are carried out at 680°C and 600°C respectively. From the vapour pressures of Zn and Cd at these temperatures, estimate the $P_{\text{H}_2}/P_{\text{H}_2\text{S}}$ ratio for each reaction, assuming equilibrium conditions.

Q4. a) In many vacuum systems there is a gate valve consisting of a gasketed metal plate that acts to isolate the chamber above from the pumps below. (14Mk)

i) A sample is introduced into the chamber at 760 torr while the

Isolated pumps are maintained at 10^{-6} torr. For a 15-cm-diameter opening, what force acts on the valve plate to seal it?

- iii) The chamber is forepumped to a pressure of 10^{-6} torr. What force now acts on the valve plate?
- b) Describe the turbo molecular pumps, what are their benefits in comparison to the diffusion pump? (6M)
- Q5. a) Distinguish between evaporation and sputtering. Discuss the differences in (i) production in vapour species, (ii) gas phase and (iii) the condensed film for the two cases. (6M)
- b) An aluminum film was thermally deposited at a rate of $1\mu\text{m}/\text{min}$ at 25°C and oxygen content of the film was 10^{-3} . What was the partial pressure of oxygen in the system? (8M)
- c) In a dc planar magnetron system operating 1000 V, the anode – cathode spacing is 10 cm. What magnetic field should be applied to trap electron within 1 cm of the target? (6M)